AMENDMEN'T TRANSMITTAL LETTER (Large Entity) Applicant(s): Hoiman HUNG et al.									Docket No. AM-3245		
		Date ch 1999	AU6 1	3 2001)C11	Examiner A. Olsen			Gi	roup Art Unit	
Invention: ENHANCEMENT OF SILICON OXIDE ETCH REATE AND SUBSTRATE SELECTIVITY WITH XENON ADDITION											
TO THE ASSISTANT COMMISSIONER FOR PATENTS:											
Transmitted herewith is an amendment in the above-identified application. The fee has been calculated and is transmitted as shown below.											
CLAIMS AS AMENDED											
	CLAIMS REMAINING AFTER AMENDMENT		HIGHEST # PREV. PAID FOR		ıR		NUMBER EXTRA		RATE		ADDITIONAL FEE
TOTAL CLAIMS	22	-	22		=		0	х	\$18.	00	\$0.00
NDEP. CLAIMS 4 -			3	=	=		1	х	\$80.	00	\$80.00
Multiple Dependent Claims (check if applicable) \$0.00											
TOTAL ADDITIONAL FEE FOR THIS AMENDMENT											\$80.00
 No additional fee is required for amendment. Please charge Deposit Account No. in the amount of A duplicate copy of this sheet is enclosed. ✓ A check in the amount of \$80.00 to cover the filing fee is enclosed. ✓ The Commissioner is hereby authorized to charge payment of the following fees associated with this communication or credit any overpayment to Deposit Account No. 50-0636 A duplicate copy of this sheet is enclosed. Any additional filing fees required under 37 C.F.R. 1.16. Any patent application processing fees under 37 CFR 1.17. Charles S. Guenzer, Reg. No. 30,640 (650) 566-8040 Mailing Address: Applied Materials, Inc.											
II.								I under 37 C.F.R. 1.8 and is addressed to the mmissioner for Patents, Washington, D.C. J. C. Wallowy Ture of Person Mailing Correspondence			

cc:

P11LARGE/REV06

Ingrid C. Mallory

Typed or Printed Name of Person Mailing Correspondence